



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re United States Patent Application of:

Docket No.: ATMI-668 (7493)

Applicants: **RATH, Melissa K., et al.**

Conf. No.: 4823

Application No.: 10/792,038

Art Unit: 1752

Date Filed: March 3, 2004

Examiner: LE, Hoa Van

**Title: COMPOSITION AND
PROCESS FOR POST-ETCH
REMOVAL OF
PHOTORESIST AND/OR
SACRIFICIAL ANTI-
REFLECTIVE MATERIAL
DEPOSITED ON A
SUBSTRATE**

Customer No.: 24239

EXPRESS MAIL CERTIFICATE

I hereby certify that I am mailing the attached documents to the Commissioner for Patents on the date specified, in an envelope addressed to Mail Stop RCE, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 and Express Mailed under the provisions of 37 CFR 1.10.

Justin A. Lee

Tristan Anne Fuierer

January 24, 2006

Date _____

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SUBMISSION OF POWER OF ATTORNEY AND STATEMENT UNDER 37 CFR 3.73(b); PRELIMINARY AMENDMENT; AND REQUEST FOR CONTINUED EXAMINATION IN UNITED STATES PATENT APPLICATION NO. 10/792,038

Mail Stop RCE
Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450

Sir:

Prior to examination of the above-identified RCE patent application, please amend the claims, as set out in the following **Section I (the Claims)**.

Remarks addressing the substance of the December 23, 2005 Advisory Action are set out in the **Section II (Remarks)** hereof.